**PATENT** 

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

n re: Ryu et al.

erial No.: 09/911,995

#iled: July 24, 2001

SILICON CARBIDE POWER METAL-OXIDE SEMICONDUCTOR FIELD

EFFECT TRANSISTORS HAVING A SHORTING CHANNEL AND METHODS OF FABRICATING SILICON CARBIDE METAL-OXIDE SEMICONDUCTOR FIELD EFFECT TRANSISTORS HAVING A

SHORTING CHANNEL

Date: October 22, 2001

Group Art Unit: 2811

Confirmation No.: 5240

Commissioner for Patents Washington, DC 20231

## INFORMATION DISCLOSURE STATEMENT CITATION UNDER 37 C.F.R. § 1.97

Sir:

Attached is a list of documents on form PTO-1449 together with a copy of each identified document. It is requested that these documents be considered by the Examiner and officially made of record in accordance with the provisions of 37 C.F.R. § 1.97 and Section 609 of the MPEP.

No item of information contained in this Statement was cited from a foreign patent office in a counterpart foreign application.

Respectfully submitted,

Timothy J. O'Sullivan Registration No. 35,632

**Customer Number:** 

20792

PATENT TRADEMARK OFFICE

**CERTIFICATE OF MAILING** 

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class main an envelope addressed to: Commissioner for Patents, Washington, DC 20231 on October 22, 2001.

Traci A. Brown

Date of Signature: October 22, 2001